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UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 6,784,052 B2
DATED : August 31, 2004
INVENTOR(S) : Schuegraf et al.

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 5,

Line 34, replace "photoresis:" with -- photoresist --.

Line 46, delete "to" after "describing".

Column 7,

Line 64, replace "provide" with -- provided --.

Line 52, replace "soaced" with -- spaced --.

Line 64, replace "region" with -- region, --.

Line 65, insert -- over -- after "layer".

Column 8,

Line 31, replace "ever" with -- over --.

Line 38, replace "deDeistion step; xetching;" with -- deposition step; etching --.

Line 39, replace "wlectrically" with -- electrically --.

Line 41, replace "deDeistion steD;" with -- deposition step --.

Line 42, replace "matenal" With -- material --.

Signed and Sealed this

Fifth Day of April, 2005



JON W. DUDAS
Director of the United States Patent and Trademark Office